

L Number	Hits	Search Text	DB	Time stamp
1	21164	(silicon adj1 dioxide) near15 substrate	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/19 12:17
2	79512	369/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/19 11:31
3	86	((silicon adj1 dioxide) near15 substrate) and 369/\$.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/19 11:32
4	6173	(heat or thermal) near10 (silicon adj1 dioxide)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/19 11:39
5	3035	((silicon adj1 dioxide) near15 substrate) and ((heat or thermal) near10 (silicon adj1 dioxide))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/19 11:39
6	10	369/\$.ccls. and ((silicon adj1 dioxide) near15 substrate) and ((heat or thermal) near10 (silicon adj1 dioxide)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/19 12:09
7	7	("5929438").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/19 12:10
8	347	(silicon adj1 dioxide) near15 (probe or tip)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/19 12:17
9	12172	stm or afm	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/19 12:17
10	69	((silicon adj1 dioxide) near15 (probe or tip)) and (stm or afm)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/02/19 12:17